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ISSUE DATE**

U.S. UTILITY Patent Application

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EXAMINER

****APPLICANTS:** Hu Rongxiang, Kim Yongbae, Lee Sang-Yun, Takikawa Hiroaki, Dou Shumay, Neuman Sarah, Schoenborn Philippe, Chao Keith, Vijay Dilip, Zhang Kai, Eda Vasaiichi.

****CONTINUING DATA VERIFIED:**

****FOREIGN APPLICATIONS VERIFIED:**

PG-PUB DO NOT PUBLISH ☐

RESCIND ☐

Foreign priority claimed ☐ yes ☒ no
35 USC 119 conditions met ☐ yes ☒ no
Verified and Acknowledged Examiner's initials

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TITLE : Method of preventing resist poisoning in dual damascene structures

U.S. DEPT. OF COM. (PAT. 1. TM-P10-a)(Rev. 12-94)

NOTICE OF ALLOWANCE MAILED

Amount Due Date Paid

ISSUE FEE

Amount Due Date Paid



TERMINAL

DISCLAIMER

Assistant Examiner

Primary Examiner

PREPARED FOR ISSUE

CLAIMS ALLOWED

Total Claims

Print Claim for
O.G.

DRAWING

Sheet Drawg.

Fig. Drawg.

Print Fig.

Application Examiner

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